Number	Hits	Search Text	DB	Time stamp
Ivuilloci	1668	probe near3 (clean or cleaner or cleaning)	USPAT;	2003/05/08 09:21
	1000	procentate (create a create of	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	221672	silicone polysiloxane polyorganosiloxane polydiorganosiloxane	USPĀT;	2003/05/07 15:24
	331673	organopolysiloxane organosiloxane diorganopolysiloxane siloxane	US-PGPUB;	
			EPO; JPO;	
		organosilicone	DERWENT;	
			IBM_TDB	
		() and (giliagne polysilovane	USPAT;	2003/05/07 15:25
	120	(probe near3 (clean or cleaner or cleaning)) and (silicone polysiloxane	US-PGPUB;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	EPO; JPO;	
·		organosiloxane diorganopolysiloxane siloxane organosilicone)	DERWENT;	
			IBM_TDB	2002/05/07 15:2
	59	((probe near3 (clean or cleaner or cleaning)) and (silicone polysiloxane	USPAT;	2003/05/07 15:2
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)) and	EPO; JPO;	
	!	substrate	DERWENT;	l
	l		IBM_TDB	
	16	(((probe near3 (clean or cleaner or cleaning)) and (silicone polysiloxane	USPAT;	2003/05/07 15:3
	10	polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
	1	organosiloxane diorganopolysiloxane siloxane organosilicone)) and	EPO; JPO;	
		substrate) and semiconduct\$4	DERWENT;	
		substrate) and semiconducts4	IBM TDB	
	_	(cilicone nolysiloyane	USPAT;	2003/05/07 15:3
	5	((((probe near3 (clean or cleaner or cleaning)) and (silicone polysiloxane	US-PGPUB;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	EPO; JPO;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)) and	DERWENT;	
		substrate) and semiconduct\$4) and (probe adj card)		
			IBM_TDB	2003/05/07 15:3
	5371	probe adj card	USPAT;	2003/03/07 13.5
	1		US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	188	(probe adj card) and substrate and (silicone polysiloxane	USPAT;	2003/05/07 15:
	1.00	polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)	EPO; JPO;	
	1	organosnovano diorganopos, secondo	DERWENT;	
			IBM_TDB	
	1.52	((probe adj card) and substrate and (silicone polysiloxane	USPAT;	2003/05/07 15:
•	153	polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)) and	EPO; JPO;	
		organoshoxane diorganopolyshoxane shoxane organoshicone)) and	DERWENT;	
		semiconduct\$4	IBM TDB	
			USPAT;	2003/05/07 15:
•	2121	probe near5 (clean or cleaner or cleaning)	US-PGPUB;	l .
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	2002/05/07 15
-	1	8 (((probe adj card) and substrate and (silicone polysiloxane	USPAT;	2003/05/07 15
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)) and	EPO; JPO;	
		semiconduct\$4) and (probe near5 (clean or cleaner or cleaning))	DERWENT	;
		The state of the s	IBM_TDB	
		4 "6130104"	USPAT;	2003/05/07 15
•		4 VIJVIVT	US-PGPUB	;
			EPO; JPO;	1
	1		DERWENT	:
			IBM_TDB	´

-	1428	probe near5 (cleaner or cleaning)	USPAT;	2003/05/07 15:50
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	8	(((probe adj card) and substrate and (silicone polysiloxane	USPAT;	2003/05/07 15:51
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	US-PGPUB;	
		organosiloxane diorganopolysiloxane siloxane organosilicone)) and	EPO; JPO;	
		semiconduct\$4) and (probe near5 (cleaner or cleaning))	DERWENT;	
	10432	(charaina an acasa an asitty an manch and) (cub stanta	IBM_TDB	2002/05/07 17:02
-	10432	(abrasive or coarse or gritty or roughened) near4 (substrate or support)	USPAT; US-PGPUB;	2003/05/07 16:03
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	1289	((abrasive or coarse or gritty or roughened) near4 (substrate or support))	USPAT;	2003/05/07 15:54
	120)	and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane	US-PGPUB;	2003/03/07 13.34
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	EPO; JPO;	
		organosilicone)	DERWENT;	
		(IBM TDB	
•	1	(((abrasive or coarse or gritty or roughened) near4 (substrate or support))	USPAT;	2003/05/07 15:55
		and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane	US-PGPUB;	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	EPO; JPO;	
		organosilicone)) and (probe near5 (cleaner or cleaning))	DERWENT;	
			IBM_TDB	
_	6	(((abrasive or coarse or gritty or roughened) near4 (substrate or support))	USPĀT;	2003/05/07 15:55
		and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane	US-PGPUB;	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	EPO; JPO;	
		organosilicone)) and (probe adj card)	DERWENT;	
			IBM_TDB	
-	9300	428/446-454.ccls.	USPAT;	2003/05/07 15:56
			US-PGPUB;	
1			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	27	(((abrasive or coarse or gritty or roughened) near4 (substrate or support))	USPAT;	2003/05/07 15:56
		and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane	US-PGPUB;	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	EPO; JPO;	
		organosilicone)) and 428/446-454.ccls.	DERWENT;	
	26401	(-11)	IBM_TDB	2002/05/05 15 55
-	36491	(silicone polysiloxane polyorganosiloxane polydiorganosiloxane	USPAT;	2003/05/07 15:57
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone) same vinyl	US-PGPUB;	
		organosmeone) same vinyi	EPO; JPO; DERWENT;	
			IBM TDB	
	10	(((((abrasive or coarse or gritty or roughened) near4 (substrate or support))	USPAT;	2003/05/07 15:57
		and (silicone polysiloxane polyorganosiloxane polydiorganosiloxane	US-PGPUB;	2003/03/07 13.37
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	EPO; JPO;	
		organosilicone)) and 428/446-454.ccls.) and ((silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM_TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone) same	15.11_155	
		vinyl)		
-	98150	(abrasive or coarse or gritty or roughened or rough\$6 or etched or	USPAT;	2003/05/07 16:19
		etching) near4 (substrate or support)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	921	((silicone polysiloxane polyorganosiloxane polydiorganosiloxane	USPĀT;	2003/05/07 16:05
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	US-PGPUB;	
		organosilicone) same vinyl) and ((abrasive or coarse or gritty or	EPO; JPO;	
		roughened or rough\$6 or etched or etching) near4 (substrate or support))	DERWENT;	
			IBM_TDB	

-	. 42	(((silicone polysiloxane polyorganosiloxane polydiorganosiloxane	USPAT;	2003/05/07 16:13
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	US-PGPUB;	
		organosilicone) same vinyl) and ((abrasive or coarse or gritty or	EPO; JPO;	
		roughened or rough\$6 or etched or etching) near4 (substrate or support)))	DERWENT;	
		and 428/446-454.ccls.	IBM_TDB	
-	1726	427/307-309.ccls.	USPAT;	2003/05/07 16:14
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	13	427/307-309.ccls. and ((silicone polysiloxane polyorganosiloxane	USPĀT;	2003/05/07 16:15
		polydiorganosiloxane organopolysiloxane organosiloxane	US-PGPUB;	
		diorganopolysiloxane siloxane organosilicone) same vinyl)	EPO; JPO;	
		diorganopolyshokant shokant organismicons) same vinyi)	DERWENT;	
			IBM_TDB	
	11	427/307-309.ccls. and ((silicone polysiloxane polyorganosiloxane	USPAT;	2003/05/07 16:16
-	11			2003/03/07 10:10
		polydiorganosiloxane organopolysiloxane organosiloxane	US-PGPUB;	
		diorganopolysiloxane siloxane organosilicone) same vinyl) and	EPO; JPO;	
		(substrate or support)	DERWENT;	
			IBM_TDB	
-	3	(427/307-309.ccls. and ((silicone polysiloxane polyorganosiloxane	USPAT;	2003/05/07 16:17
		polydiorganosiloxane organopolysiloxane organosiloxane	US-PGPUB;	
		diorganopolysiloxane siloxane organosilicone) same vinyl) and	EPO; JPO;	
		(substrate or support)) and ((abrasive or coarse or gritty or roughened or	DERWENT;	
		rough\$6 or etched or etching) near4 (substrate or support))	IBM_TDB	
_	98587	(abrasive or coarse or gritty or roughened or rough or rough\$6 or etched	USPĀT;	2003/05/08 09:28
		or etching or abraded) near4 (substrate or support)	US-PGPUB;	
		committee of the commit	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	7394	hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane		2003/05/08 09:25
_	/394	polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	USPAT;	2003/03/08 09.23
			US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
		polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM_TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone))		
-	12511	vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone	USPAT;	2003/05/08 09:27
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane	US-PGPUB;	
	-	polydiorganosiloxane organopolysiloxane organosiloxane	EPO; JPO;	
		diorganopolysiloxane siloxane organosilicone))	DERWENT;	
	1		IBM_TDB	
-	2098	(hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane	USPAT;	2003/05/14 09:52
		polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
		polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and	15155	
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone		
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane		
		polydiorganosiloxane organopolysiloxane organosiloxane		
		diorganopolysiloxane siloxane organosilicone)))		
-	335450	(abrasive or coarse or gritty or roughened or rough or rough\$6 or etched	USPAT;	2003/05/08 09:46
		or etching or abraded or pitted or porous or microstructured) same	US-PGPUB;	
		(substrate or support)	EPO; JPO;	
			DERWENT;	
			IBM_TDB	!

-	141	((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydrogensilicone polyhydrosilicone polyhydrosilicone polyhydrogensilicone polyhydrosilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosilicone))) and (vinylsiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse or gritty or roughened or rough or rough\$6 or etched or etching or abraded or pitted or porous or microstructured) same (substrate or support))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 09:46
-	336765	(abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or etched or etching or abraded or pitted or porous or microstructured) same (substrate or support)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 12:48
-	142	((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone polyhydrogensilicone polyhydrogensilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organopolysiloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or etched or etching or abraded or pitted or porous or microstructured) same (substrate or	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:11
-	25	support)) (((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydrosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone polyhydrogensilicone polyhydrogensilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organopolysiloxane organosilicone))) and (vinylsiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosiloxane diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or etched or etching or abraded or pitted or porous or microstructured) same (substrate or support))) and probe	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:05
	10		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:06

	 .		VIOD 4 T	2002/05/00 11 06
•	1	(((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane	USPAT;	2003/05/08 11:06
		polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
		polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM_TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and	·	
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone		
•		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane		
	1	polydiorganosiloxane organopolysiloxane organosiloxane		
		diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse		
		or gritty or grit or roughened or rough or rough\$6 or etched or etching or		
		abraded or pitted or porous or microstructured) same (substrate or		
		support))) and semiconduct\$5 and probe	TIOD ATC	2002/05/09 11:12
	25	(((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane	USPAT;	2003/05/08 11:12
		polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
		polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM_TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and		
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone		
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane		
		polydiorganosiloxane organopolysiloxane organosiloxane		
		diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse		
		diorganopolyshoxane shoxane organoshicone)))) and ((ablasive of coarse		
		or gritty or grit or roughened or rough or rough\$6 or etched or etching or		
		abraded or pitted or porous or microstructured) same (substrate or		
		support))) and abrasive		******
	10	(((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane	USPAT;	2003/05/08 11:24
		polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
		polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM TDB	
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and	_	
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone		
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane		
	İ	polydiorganosiloxane organopolysiloxane organosiloxane		
		diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse		
		or gritty or grit or roughened or rough or rough\$6 or etched or etching or		
		abraded or pitted or porous or microstructured) same (substrate or		
		support))) and (abrasive same (substrate or support))		
-	42	(((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane	USPAT;	2003/05/08 11:31
		polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone	US-PGPUB;	
		hydrogensilicone polyhydrosilicone polyhydridosilicone	EPO; JPO;	
	ļ	polyhydrogensilicone (hydrogen near4 (silicone polysiloxane	DERWENT;	
		polyorganosiloxane polydiorganosiloxane organopolysiloxane	IBM TDB	
			15155	
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and		
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone		
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane		
		polydiorganosiloxane organopolysiloxane organosiloxane		
		diorganopolysiloxane siloxane organosilicone)))) and ((abrasive or coarse		
		or gritty or grit or roughened or rough or rough\$6 or etched or etching or		
		abraded or pitted or porous or microstructured) same (substrate or		
		support))) and ((substrate or support) same (transition alloy copper		
	ì	nickel palladium tungsten rhenium rhobium cobalt))		
	1442		USPAT;	2003/05/08 11:3
-	1443	(substrate or support) same (dendrit\$5)		2003/03/06 11.3
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	ı	l .	IBM TDB	i .

		<u> </u>		
-	0	((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydrogensilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:33
		organosiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organopolysiloxane diorganopolysiloxane siloxane organosilicone)))) and ((substrate or support) same (dendrit\$5))		
-	21	((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydrogensilicone polyhydrogensilicone polyhydrosilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:34
-	11	diorganopolysiloxane siloxane organosilicone)))) and (dendrit\$5) ((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydrogensiloxane polyhydrosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone polyhydrogensilicone polyhydrogensiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone)))) and ((substrate or support) same (groov\$4 or ribs or ribbed))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:52
-	126	428/145.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/05/08 11:52
-	0	428/145.ccls. and ((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydrosiloxane polyhydrosiloxane polyhydrosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organopolysiloxane organopolysiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:52
-	380	428/\$.ccls. and ((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone polyhydrogensilicone (hydrogen near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polyorganosiloxane organopolysiloxane organopolysiloxane organopolysiloxane organosiloxane diorganopolysiloxane siloxane organosiloxane diorganopolysiloxane siloxane organosilicone))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 11:53
-	546244	(abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or etched or etching or abraded or pitted or porous or microstructured or groov\$4 or ribs or ribbed or dentrit\$5) same (substrate or support)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/08 12:51

-	75	(428/\$.ccls. and ((hydrosiloxane hydridosiloxane hydrogensiloxane polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane	USPAT; US-PGPUB;	2003/05/08 13:22
		hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone polyhydrogensilicone (hydrogen near4 (silicone	EPO; JPO; DERWENT;	
		polysiloxane polyorganosiloxane polydiorganosiloxane	IBM TDB	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	IBM_IBB	
		organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone		
		polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane		
		polyorganosiloxane polydiorganosiloxane organopolysiloxane		
		organosiloxane diorganopolysiloxane siloxane organosilicone))))) and ((abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or		
		etched or etching or abraded or pitted or porous or microstructured or		
		groov\$4 or ribs or ribbed or dentrit\$5) same (substrate or support))		
-	2	"20020053734"	USPAT;	2003/05/08 13:44
			US-PGPUB;	i
			EPO; JPO;	
			DERWENT; IBM TDB	
-	39	"4774111"	USPAT;	2003/05/08 13:44
			US-PGPUB;	2000/02/00
			EPO; JPO;	
			DERWENT;	
_	19	"4774111" and ((hydrosiloxane hydridosiloxane hydrogensiloxane	IBM_TDB USPAT;	2003/05/08 13:45
	19	polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane	USPAT; US-PGPUB;	2003/03/06 13:43
		hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone	EPO; JPO;	
		polyhydridosilicone polyhydrogensilicone (hydrogen near4 (silicone	DERWENT;	
		polysiloxane polyorganosiloxane polydiorganosiloxane	IBM_TDB	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane		
		organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane		
		polyorganosiloxane polydiorganosiloxane organopolysiloxane		
		organosiloxane diorganopolysiloxane siloxane organosilicone))))		
-	1	"4774111" and ((hydrosiloxane hydridosiloxane hydrogensiloxane	USPAT;	2003/05/08 13:45
		polyhydrosiloxane polyhydridosiloxane polyhydrogensiloxane hydrosilicone hydridosilicone hydrogensilicone polyhydrosilicone	US-PGPUB; EPO; JPO;	
		polyhydridosilicone polyhydrogensilicone (hydrogen near4 (silicone	DERWENT;	
		polysiloxane polyorganosiloxane polydiorganosiloxane	IBM TDB	
		organopolysiloxane organosiloxane diorganopolysiloxane siloxane	_	
	•	organosilicone))) and (vinylsiloxane polyvinylsiloxane vinylsilicone		
		polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane		
		organosiloxane diorganopolysiloxane siloxane organosilicone)))) and		
		((abrasive or coarse or gritty or grit or roughened or rough or rough\$6 or		
	1	etched or etching or abraded or pitted or porous or microstructured or		
	10546	groov\$4 or ribs or ribbed or dentrit\$5) same (substrate or support))	HODAT	2002/05/14 00 55
-	12544	vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane	USPAT; US-PGPUB;	2003/05/14 09:53
		polyvinyisincone (vinyi near4 (sincone polysiloxane polyorganosiloxane polydiorganosiloxane organopolysiloxane organosiloxane	EPO; JPO;	
		diorganopolysiloxane siloxane organosilicone))	DERWENT;	
			IBM_TDB	
-	58	"6056627" "5690749" "4778326"	USPAT;	2003/05/14 09:53
			US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM_TDB	
-	0	(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone	USPAT;	2003/05/14 09:55
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane	US-PGPUB;	
		polydiorganosiloxane organopolysiloxane organosiloxane	EPO; JPO;	
		diorganopolysiloxane siloxane organosilicone))) and ("6056627"	DERWENT;	
	I	"5690749" "4778326")	IBM_TDB	

-	306	"4757255" "4954774" "5198752" "5198753" "5568054" "5834946"	USPAT;	2003/05/14 09:57
		"6140616" "6184053" "5476211" "5917707" "6110823" "6255126"	US-PGPUB;	
	-	"6169409"	EPO; JPO;	
			DERWENT;	
		•	IBM TDB	
-	0	(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone	USPĀT;	2003/05/14 09:57
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane	US-PGPUB;	
		polydiorganosiloxane organopolysiloxane organosiloxane	EPO; JPO;	
		diorganopolysiloxane siloxane organosilicone))) and ("4757255"	DERWENT;	
		"4954774" "5198752" "5198753" "5568054" "5834946" "6140616"	IBM TDB	
		"6184053" "5476211" "5917707" "6110823" "6255126" "6169409")		
	1	wo-200033089-\$.did.	USPAT;	2003/05/14 09:57
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	2	wo-9514314-\$.did.	USPAT;	2003/05/14 09:57
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	1	wo-9617378-\$.did.	USPAT;	2003/05/14 09:58
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	4	wo-200033089-\$.did. wo-9514314-\$.did. wo-9617378-\$.did.	USPAT;	2003/05/14 09:58
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		(2 000022000 ft 111	IBM_TDB	
•	0	(wo-200033089-\$.did. wo-9514314-\$.did. wo-9617378-\$.did.) and	USPAT;	2003/05/14 09:58
		(vinylsiloxane polyvinylsiloxane vinylsilicone polyhydrosilicone	US-PGPUB;	
		polyvinylsilicone (vinyl near4 (silicone polysiloxane polyorganosiloxane	EPO; JPO;	
		polydiorganosiloxane organopolysiloxane organosiloxane	DERWENT;	
		diorganopolysiloxane siloxane organosilicone)))	IBM TDB]